



IPM
501.36694CV4

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): S. Shukuri, et al.

Application No. 10/635,511

Filed: August 7, 2003

For: SEMICONDUCTOR INTEGRATED CIRCUIT DEVICE HAVING
DEPOSITED LAYER FOR GATE INSULATION

Group: 2814

Examiner: L. Pham

AMENDMENT

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

December 6, 2004

Sir:

In response to the Office Action mailed November 5, 2004, please amend the above-identified application as listed in the following, and as set forth on the following pages:

Amendments to the Claims; and

Remarks are included following the amendments.